

**Ho Fung College (Sponsored by Sik Sik Yuen)**  
**Notes on Application for Secondary One Discretionary Places (2019-2020)**

1. Number of secondary one discretionary places: 41
2. Application period: 3/1/2019 –17/1/2019 (both dates inclusive)
3. Ways to obtain school application form:
  - (1) Collect school application form in person at Ho Fung College (448, Wo Yi Hop Road, Sheung Kwai Chung, N.T.)  
Monday – Friday: 09:00 – 16:30  
Saturday: 09:00 – 12:00
  - (2) Download school application form from Ho Fung College’s Homepage (<http://www.hofung.edu.hk>)
4. Documents to be submitted:
  - (1) School application form;
  - (2) EDB’s application form for S1 discretionary place;
  - (3) Photocopy of H.K.I.D Card or Birth Certificate;
  - (4) Photocopy of all P.5 and P.6 half-yearly school reports (P.6 half-yearly school report can be submitted later in case it is not released at the time of application);
  - (5) Photocopies of certificates of both internal and external awards received from P.4 to P.6;
  - (6) Self-addressed envelope with student’s name and stamp.

Remarks:

  - i. ALL the above documents should be placed in a clear plastic folder.
  - ii. Recommendation letter from the headmaster or the primary school is NOT required.
  - iii. It is NOT necessary for the applicant to submit application form in person.
5. ALL APPLICANTS will be invited to attend an interview held on 17<sup>th</sup> March, 2019. Applicants will receive notification letters before mid of March, 2019.
6. Admission criteria and weightings:

(1) Academic achievement	50%
(2) Performance in interview	35%
(3) Performance in extra-curricular activities and services	15%
(4) Conduct being B or above	
7. In accordance to guidelines on Secondary School Places Allocation (SSPA) System, each student may apply for NOT MORE THAN TWO secondary schools, otherwise his/her chance of acquiring a discretionary place will be forfeited.
8. Secondary school places allocation results will be released on 9<sup>th</sup> July 2019. Our school will NOT notify individual application of the result of application for secondary one discretionary places.